

Ultrafast Photocurrent Measurement of the Escape Time of Electrons and Holes from Carbon Nanotube *p-i-n* Photodiodes

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Ultrafast photocurrent measurements are performed on individual carbon nanotube *p-i-n* photodiodes. The photocurrent response to subpicosecond pulses separated by a variable time delay Δt shows strong photocurrent suppression when two pulses overlap ($\Delta t = 0$). The picosecond-scale decay time of photocurrent suppression scales inversely with the applied bias V_{SD} , and is twice as long for photon energy above the second subband E_{22} as compared to lower energy. The observed photocurrent behavior is well described by an escape time model that accounts for carrier effective mass.

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Highly efficient photovoltaic and photodetector devices, which make use of multiple electron-hole pair generation from a single photon [1–4], require comprehensive understanding of charge carrier dynamics and their role in optoelectronic response. In order to study dynamics in nanoscale systems such as carbon nanotubes (NTs) and nanocrystal quantum dots, numerous measurements have been developed to probe the relevant time scales of electron motion in ensembles of these novel materials. In NTs, the time scale over which carrier interactions occur may range from 10^{-14} second for intrasubband relaxation [5] to greater than 10^{-9} to 10^{-7} second for radiative recombination [6–9]. However, no measurements have combined ultrafast optical and electronic techniques to probe the carrier dynamics and interactions in *individual* nanotube optoelectronic devices. While optical probes measure either the creation of electron-hole pairs or excitons (absorption), or their relaxation (emission), photocurrent measurements probe a different quantity, the photoexcited carriers that escape the junction as separate electrons and holes. This time scale is not easily accessible from optical measurements, but is key for understanding the behavior of photovoltaics.

In this Letter, we present the first ultrafast photocurrent measurements of an individual NT optoelectronic device that incorporates subpicosecond laser pulses. Using our technique, we directly probe the transit of electrons and holes through a NT *p-i-n* junction in the time domain, finding that carriers in the first subband (of effective mass m_1^*) escape the device in half the time as carriers in the second subband ($m_2^* = 2m_1^*$). Our measurements indicate that carrier escape is diffusive in forward bias and, as the escape time decreases, approaches ballistic transport in reverse bias.

Figure 1(a) shows the experimental schematic for measuring the photocurrent at ultrafast time scales. A

femtosecond Ti:sapphire laser (repetition rate $f = 75$ MHz and pulse width < 200 fs) or an optical parametric oscillator (same repetition rate and pulse width < 300 fs), with respective wavelength ranges of 780–1000 nm and 1200–1600 nm, is used to photoexcite a nanotube *p-i-n* junction, described below. The beam is focused through a microscope objective onto the NT sample in an optical cryostat at $T = 40$ K. The beam diameter is characterized using scanning photocurrent microscopy [1] and exhibits diffraction-limited Gaussian intensity distribution at the wavelengths used. We measure photocurrent response to single pulses or as a function of the time delay between two pulses. This is accomplished by splitting the output laser beam into a reference and delay beam separated by a time interval Δt . This temporal separation can be tuned by varying the optical path of the delay beam.

A schematic of the nanotube device is shown in Fig. 1(a) as described previously [1,10,11]. Gate electrodes (V_1 , V_2 , and bottom gate V_G) beneath a nanotube form a *p-i-n* junction with a source-drain (SD) contact distance of 3 microns. The I - V_{SD} curve of the device shows a diode characteristic [Fig. 1(b)] when the split gate voltages V_1 and V_2 are of opposite polarity [10]. The turn-on [or open-circuit (OC)] voltage gives an approximate measure of the band gap $V_{OC} = E_{gap}/e = E_{11}/e$ where e is the elementary charge, and standard photocurrent spectroscopy measurements [Fig. 1(c)] can be used to measure the energy E_{22} of the second subband [1,12,13]. For the device shown, referred to as device 1, these are found to be $E_{11} = 0.48$ eV and $E_{22} = 0.95$ eV.

We first measure the low temperature photocurrent at the *p-i-n* junction due to a single optical pulse train (at $f = 75$ MHz) as a function of the excitation intensity n (number of photons per pulse/cm²). Figure 2 shows photocurrent vs intensity at $V_{SD} = 0$ V for device 1. We normalize the photocurrent data by the current value at

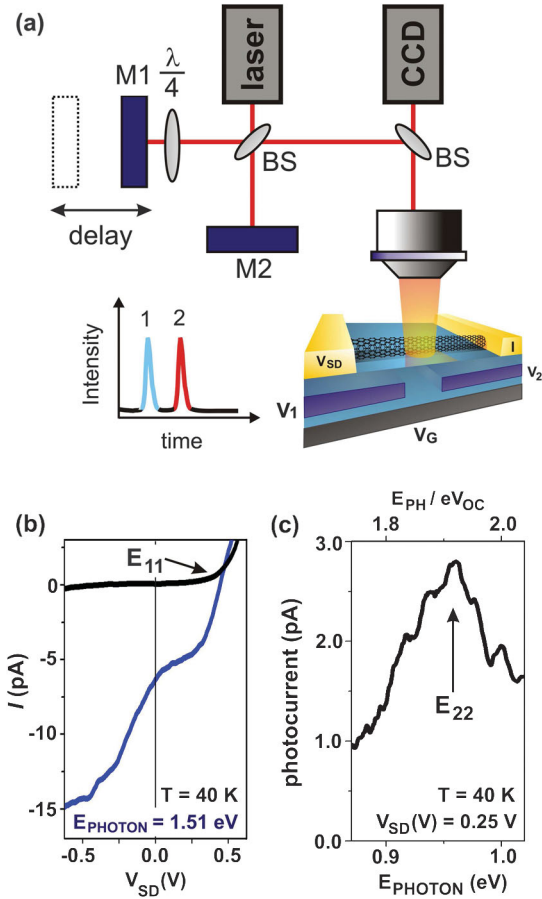


FIG. 1 (color). Experimental apparatus and photocurrent characteristics of the NT *p-i-n* photodiode. (a) Experimental apparatus: M1 translating mirror, M2 fixed mirror, BS beamsplitter. (b) I - V_{SD} characteristics at $T = 40$ K and $E_{ph} = 1.51$ eV, for device 1 with open-circuit voltage $V_{OC} = E_{11}/e = 0.48$ V, $V_1 = -8$ V, $V_2 = 8$ V, $V_G = 1$ V. (c) Photocurrent vs photon energy at $V_{SD} = 0.25$ V. All other parameters same as in (a). The top axis has been divided by V_{OC} to assign the E_{22} peak.

which one carrier is generated per pulse [inset Fig. 2(a)]: $I = ef \sim 12$ pA. The photocurrent is linear for $I/ef < 1$ but becomes sublinear above $I/ef > 1$. The sublinear behavior can be approximately described as $I \sim n^{0.3}$ [Fig. 2(b)].

The data of Fig. 2 indicate that when multiple excitations dwell simultaneously in the junction, they strongly reduce the photocurrent response, likely due to electron-hole recombination. We can use this sublinearity of the photocurrent vs intensity to probe the relevant time scale during which photoexcited excitations reside in the junction before escaping. In other words, how long must we wait before the junction is again empty? At zero time delay, two overlapping pulses will drive the photocurrent into strong sublinearity, while at long time delays the photocurrent will respond as though the pulses are independent, producing a larger current. The crossover between

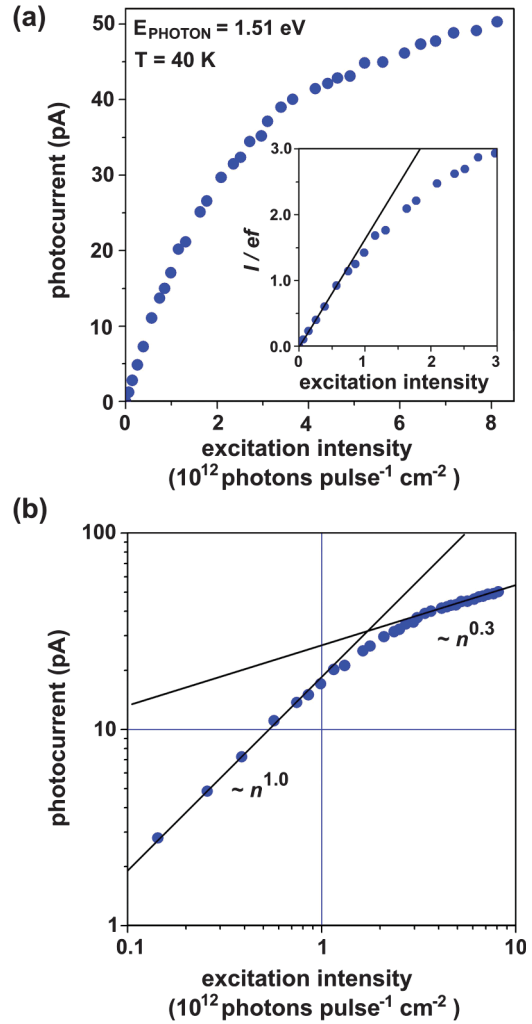


FIG. 2 (color). Single pulse photocurrent of the NT *p-i-n* photodiode. (a) Single pulse photocurrent vs optical intensity at $T = 40$ K, $E_{ph} = 1.51$ eV and $V_{SD} = 0$ V for device 1. Inset, single pulse photocurrent divided by the elementary charge e and the repetition rate of the laser f vs optical intensity. (b) Same data as (a) in log-log scale.

these two behaviors yields the escape time from the junction.

Figure 3 shows the double-pulse photocurrent measured at $V_{SD} = 0$ V and $E_{ph} = 1.51$ eV for the same device as in Fig. 2. In Fig. 3(a), as intensity increases, we observe a photocurrent dip near $\Delta t = 0$ (when the two pulses overlap). The photocurrent dip is symmetric at positive and negative time delay and has a temporal width of ~ 400 fs at low intensities (experimental detection limit) and saturates to ~ 1 ps at high intensities.

We normalize the high intensity photocurrent near $t = 0$ [Fig. 3(b)] and observe an exponential dependence vs time delay with a characteristic decay time constant $\tau = 0.8$ ps at $V_{SD} = 0$ V. In the remaining sections, we discuss the dependence of the double-pulse photocurrent decay time on source-drain bias and photon energy.

Figure 3(b) compares the normalized photocurrent vs time delay at $V_{SD} = 0$ V and $V_{SD} = -0.3$ V. As the device goes from zero bias into reverse bias, the characteristic decay time τ decreases. We extract the characteristic decay constant at many V_{SD} values and plot them in Fig. 3(c). In reverse bias, the decay time remains constant $\tau_0 \sim 0.5$ ps (labeled with a solid blue line). As V_{SD} approaches the open-circuit voltage ($V_{OC} = 0.48$ V), the decay constant τ increases rapidly to $\tau = 1.4$ ps at $V_{SD} = 0.15$ V. Because of the decrease of photocurrent as V_{SD} approaches V_{OC} , characteristic time constants cannot be extracted close to V_{OC} . In the inset to Fig. 3(c), we plot the inverse decay time $1/\tau$ as a function of V_{SD} . Importantly, the inverse decay time scales linearly with V_{SD} with a negative slope of $|s| = 2.3$ (V ps) $^{-1}$ and extrapolates to an intercept of $V_{SD} = 0.45$ V as $1/\tau$ approaches zero.

The V_{SD} dependence of the decay time suggests that τ is set by the escape of electrons and holes out of the p - i - n junction. After optical excitation, electrons and holes are separated in the built-in electric field ϵ and accelerate towards the device contacts [Fig. 3(d)]. As the electric field

increases (moving from the flat band condition at the open-circuit voltage into reverse bias), the charge carriers escape more quickly.

One model to describe this behavior is diffusive transport. During their escape from the junction, electrons and holes generated at the center of the device must travel a distance L with an electric-field dependent drift velocity $v_D = \mu \epsilon$ where μ is the mobility. From the velocity, we get an expression for the escape time of electrons and holes out of the junction

$$\tau = \frac{2L^2}{\mu(V_{OC} - V_{SD})}. \quad (1)$$

Here, $\epsilon = V/L$ is the electric field resulting from a voltage V applied over a distance L . The total applied voltage between p - and n -type regions is $V = (V_{OC} - V_{SD})/2 = (E_{gap}/e - V_{SD})/2$, and L is half the length of the intrinsic region of the device since electrons and holes are generated at the center.

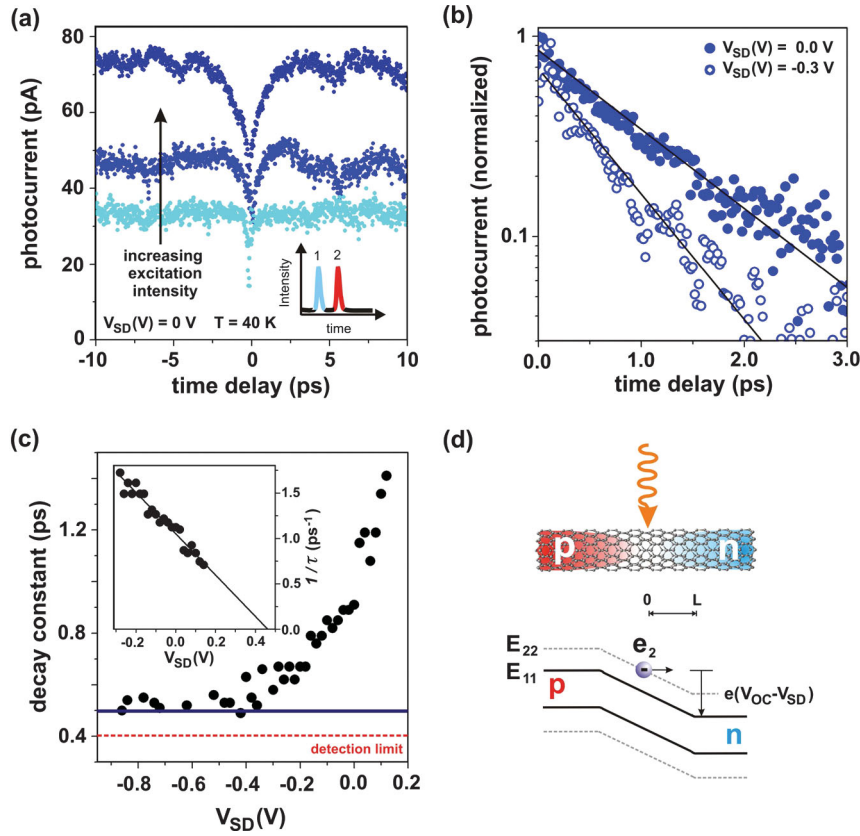


FIG. 3 (color). Double-pulse photocurrent of the NT p - i - n photodiode. (a) Photocurrent vs time delay between two pulses at $V_{SD} = 0$ V at increasing intensities ($n = 5, 11$, and 26×10^{12} photons per pulse/cm 2 from top to bottom) for the same device and conditions as Fig. 2. (b) Normalized photocurrent vs time delay at $V_{SD} = 0$ V (solid circles) and $V_{SD} = -0.3$ V (open circles). (c) Extracted decay constant vs V_{SD} . The red dashed line corresponds to the experimental resolution limit and the blue solid line labels $\tau_0 = 0.5$ ps. Inset, same data plotted as inverse decay constant $1/\tau$ vs V_{SD} . The high reverse bias decay constant data is not shown in the inset. (d) Schematic of the escape time model for electrons and holes in the p - i - n junction. Electrons (and holes, not shown) photoexcited at the center of the device travel a distance L to escape the junction.

Comparing Eq. (1) to our data, we see that the linear fit in the inset of Fig. 3(c) indeed extrapolates to the open-circuit voltage $V_{OC} \sim 0.48$ V which gives the band gap energy $E_{11} \sim 0.48$ eV. We can measure the length of the intrinsic region using scanning photocurrent microscopy [1] and find a total length of ~ 1 μm for this device. Combining half this length $L \sim 0.5$ μm with the slope from Fig. 3(c), we estimate the mobility in the intrinsic region of the p - i - n junction: $\mu = s2L^2 = 2[2.3(\text{V ps})^{-1}](0.5 \mu\text{m})^2 \sim 1 \mu\text{m}^2/\text{V ps} \sim 10^4 \text{ cm}^2/\text{V-s}$, which is comparable to mobility values measured in high-mobility NT devices [14–16]. We can also establish the upper limit of the scattering length of carriers as they transit the junction: $l \leq v_F \tau_S = v_F \mu m_2^*/e = \mu E_{22}/2ev_F \sim 0.5 \mu\text{m}$, where τ_S is the average time between scattering events, v_F is the Fermi velocity, and $m_2^* = E_{22}/2v_F^2$ is the second subband effective mass [17]. This scattering length is comparable to the intrinsic region length, indicating that transport is at the border between diffusive and ballistic. It is slightly larger than the scattering length of high-energy ($\epsilon_{OP} \sim 0.2$ eV) optical phonons [17–21], the emission of which occurs with mean free path $l_{OP} \sim 100$ nm in semiconducting nanotubes [21].

We can also compare the results to a ballistic carrier model in the p - i - n junction. In NTs, carrier energies are given by a hyperbolic band structure in which the upper limit to the velocity of electrons and holes is the Fermi velocity $v_F \sim 0.8 \mu\text{m}/\text{ps}$ [16,19,22,23]. In an electric field, ballistic transport is analogous to a relativistic electron in a static field limited by the speed of light. In the low-energy limit, the escape time varies inversely with $V_{SD}^{1/2}$, analogous to a classical ballistic particle. This is not observed in Fig. 3(c) and so rules out purely ballistic transport in forward bias.

One prediction of the diffusive model is that the escape time should vary in different subbands, since the mobility is inversely proportional to the effective mass of charge carriers. In NTs, the effective mass m^* of the second subband electrons and holes is twice that of first subband carriers ($m_2^* = 2m_1^*$) [19,22,23]. Because of the ratio of effective mass, the mobility μ (proportional to $1/m^*$) in the first subband should be twice that in the second subband ϵ_2 . Including this with Eq. (1) leads to an important experimental consequence: Carriers that are optically excited into the second subband (with effective mass $m_2^* = 2m_1^*$) should take longer than first subband carriers to accelerate out of the junction, assuming the scattering times are the same and that relaxation occurs via free carrier scattering [24]. Using ultrafast photocurrent measurements, we can probe the escape time of electrons and holes above and below E_{22} and test this hypothesis.

Figure 4 shows measurements of the double-pulse photocurrent vs time delay in forward bias above and below E_{22} for device 2. We observe that the normalized photocurrent above E_{22} (blue data) decays with a time constant

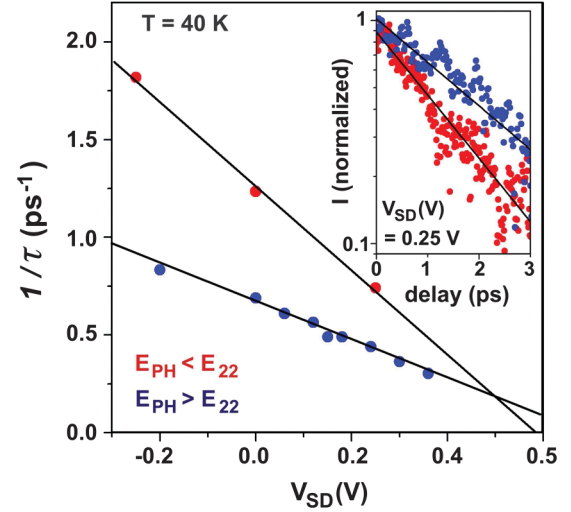


FIG. 4 (color). Double-pulse photocurrent of the NT p - i - n photodiode as a function of photon energy. Inset, normalized photocurrent at $T = 40$ K vs time delay at $E_{ph} = 1.51$ eV (blue) and $E_{ph} = 0.85$ eV (red) for device 2 with $V_{SD} = 0.25$ V. Device 2 has the same device geometry as device 1 with $V_1 = -10$ V, $V_2 = 10$ V, $V_G = 0.5$ V and $V_{OC} = 0.5$ V. Main panel: extracted inverse decay constants as a function of V_{SD} for $E_{ph} = 1.51$ eV (blue) and $E_{ph} = 0.85$ eV (red) with linear fits to the data.

of $\tau_2 \sim 2.2$ ps, while the photocurrent below E_{22} (red data) decays within $\tau_1 \sim 1.3$ ps. We plot the inverse decay times as a function of V_{SD} for photon energies above (blue) and below (red) E_{22} . Similar to device 1 [Fig. 3(c)], both data sets extrapolate to a V_{SD} value consistent with the open-circuit voltage $V_{OC} = 0.5$ V. However, while $1/\tau$ indeed scales linearly with V_{SD} , it exhibits a much steeper decent for $E_{ph} < E_{22}$. We fit both data sets and calculate the ratio of the extracted lifetimes and find $\tau_2/\tau_1 \sim 1.7$, consistent with our hypothesis.

Finally, we consider the high reverse bias region of Fig. 3(c). The escape time becomes shorter and approaches a constant value τ_0 . To understand this behavior, we can compare the escape time τ to the average time between scattering events τ_S . If the average time between scattering events $\tau_S = l/v_F$ is less than the escape time τ , then carriers undergo diffusive transport through the junction. This is observed in forward bias. However, if $\tau_S \geq \tau$, then carriers may escape the junction without scattering and the escape time approaches the ballistic limit. In this limit, the transit time for a ballistic carrier across half of the junction ($L \sim 0.5 \mu\text{m}$) would exhibit crossover behavior to a constant escape time $\tau_0 = L/v_F \sim 0.6$ ps at sufficiently high reverse bias. This crossover behavior is indeed observed [solid blue line Fig. 3(c)]. However, the measured escape time is close to the experimental resolution of 0.4 ps, so further measurements with higher temporal resolution are needed to definitively confirm ballistic transport. Note that ballistic transport in reverse bias is consistent with

previous findings in which E_{22} electrons and holes undergo highly efficient impact excitation resulting in multiple electron-hole pairs [1,25].

In summary, we have reported the first ultrafast photocurrent measurements that access the dynamics of electrons and holes in an individual nanotube p - i - n junction. These experiments open the door to future photocurrent studies exploring aspects of NT optoelectronic response that have previously been probed only through optical measurements, including electron-hole (exciton) recombination, phonon relaxation, and photoluminescence at various temperatures and photon energies. Additionally, increased temporal resolution may reveal dynamics of exciton dissociation that lead to free carriers on short time scales. Our technique will open the door for more detailed measurements of multiple electron-hole pair generation [1–4] and electron-hole recombination [26,27] in other individual nanoscale devices that incorporate nanotubes, graphene, semiconductor nanowires, and nanocrystal quantum dots.

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